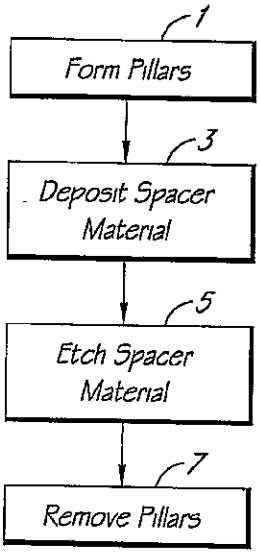
FIG. 1A


1
Form Pillars
3
Deposit Spacer Material
5
Etch Spacer Material
7
Remove Pillars

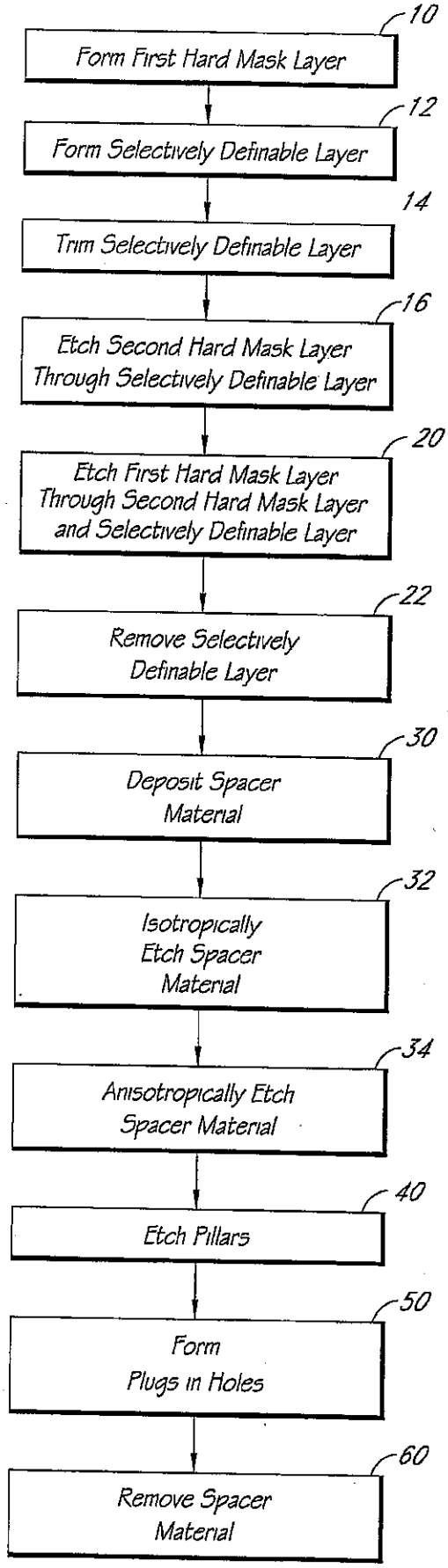

10
Form First Hard Mask Layer
12
Form Selectively Definable Layer
14
Trim Selectively Definable Layer
16
Etch Second Hard Mask Layer Through Selectively Definable Layer
20
Etch First Hard Mask Layer Through Second Hard Mask Layer and Selectively Definable Layer
22
Remove Selectively Definable Layer
30
Deposit Spacer Material
32
Isotropically Etch Spacer Material
34
Anisotropically Etch Spacer Material
40
Etch Pillars
50
Form Plugs in Holes
60
Remove Spacer Material

FIG. 1B

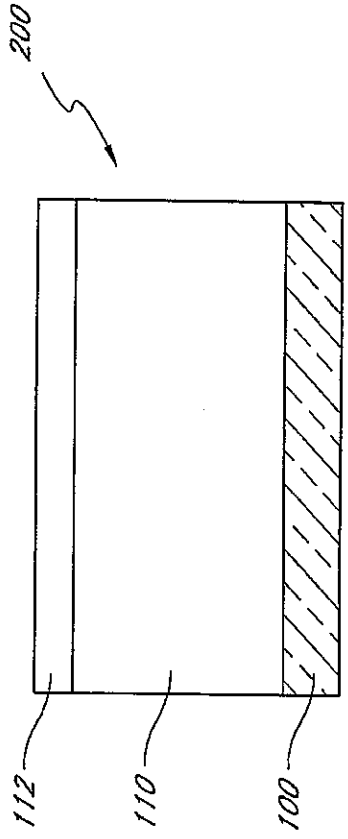


FIG. 2

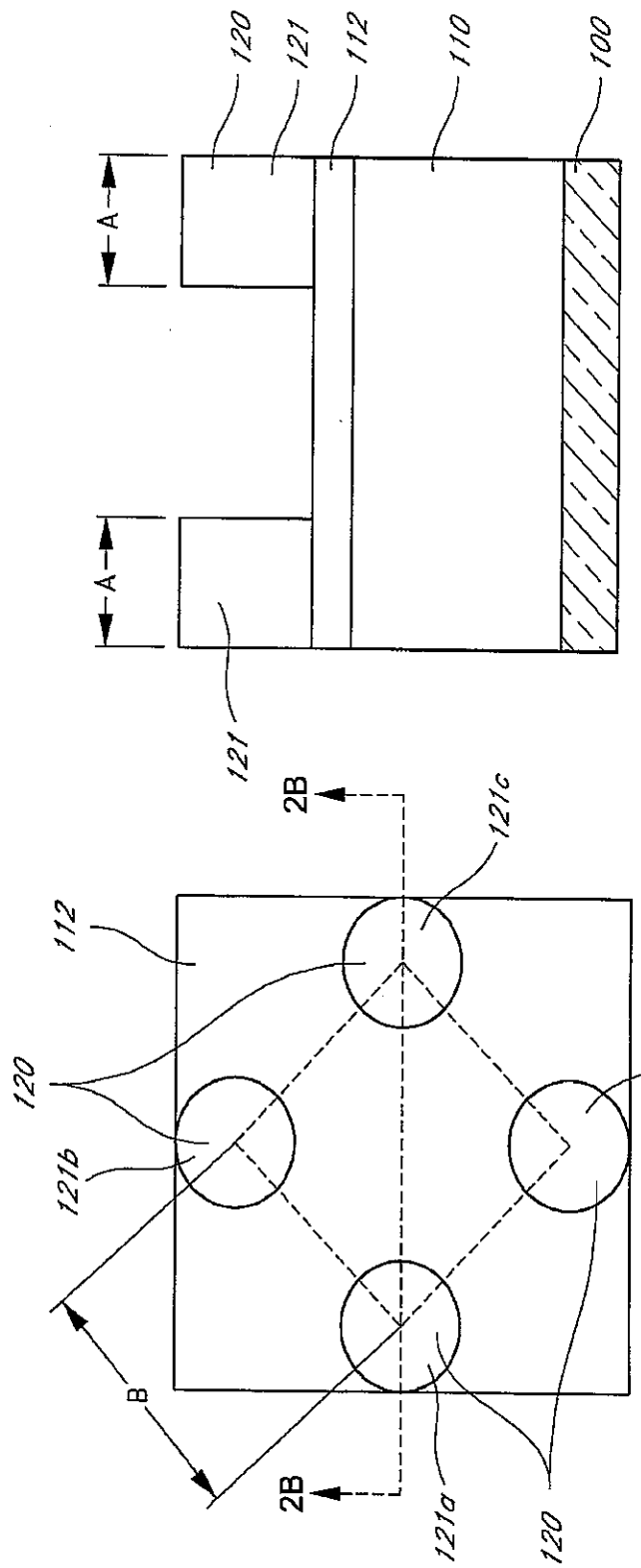

120
121
112
110
100
A
A
121
200
2B
121c
112
120
121d
121b
B
2B
121a
120
200

FIG. 2B

FIG. 2A

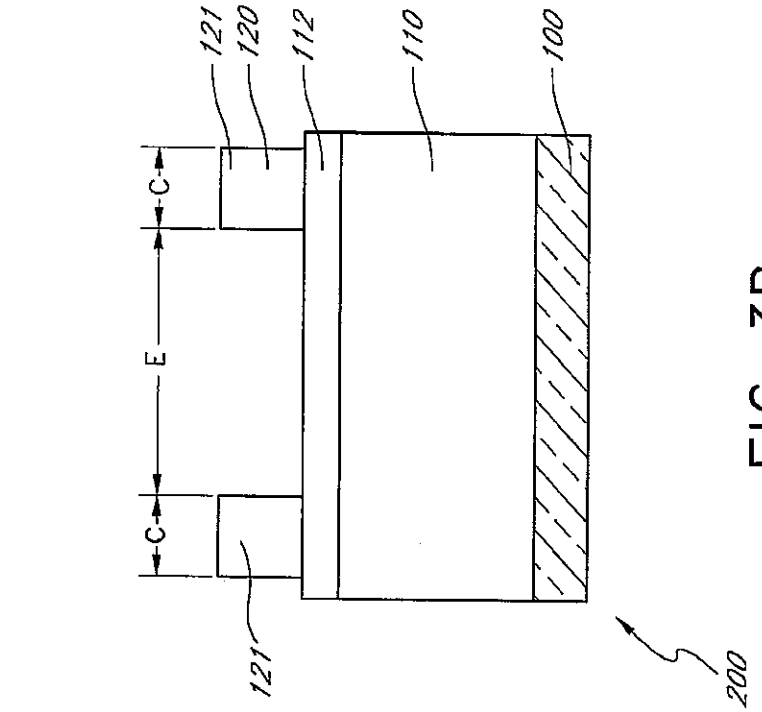

121
120
112
110
100
C
E
C
121
200

FIG. 3B

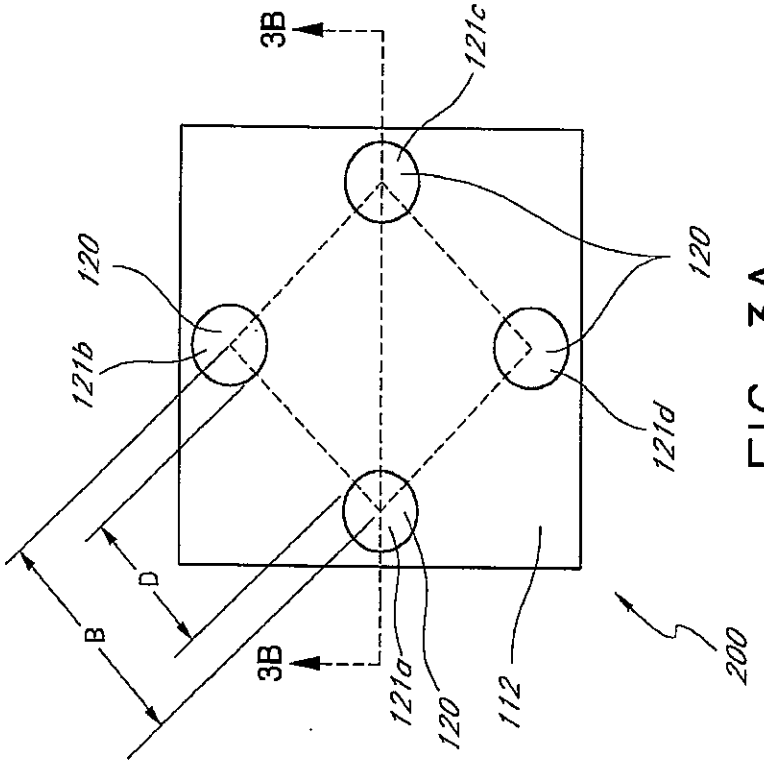

3B
121c
120
120
121b
121d
D
B
3B
121a
120
112
200

FIG. 3A

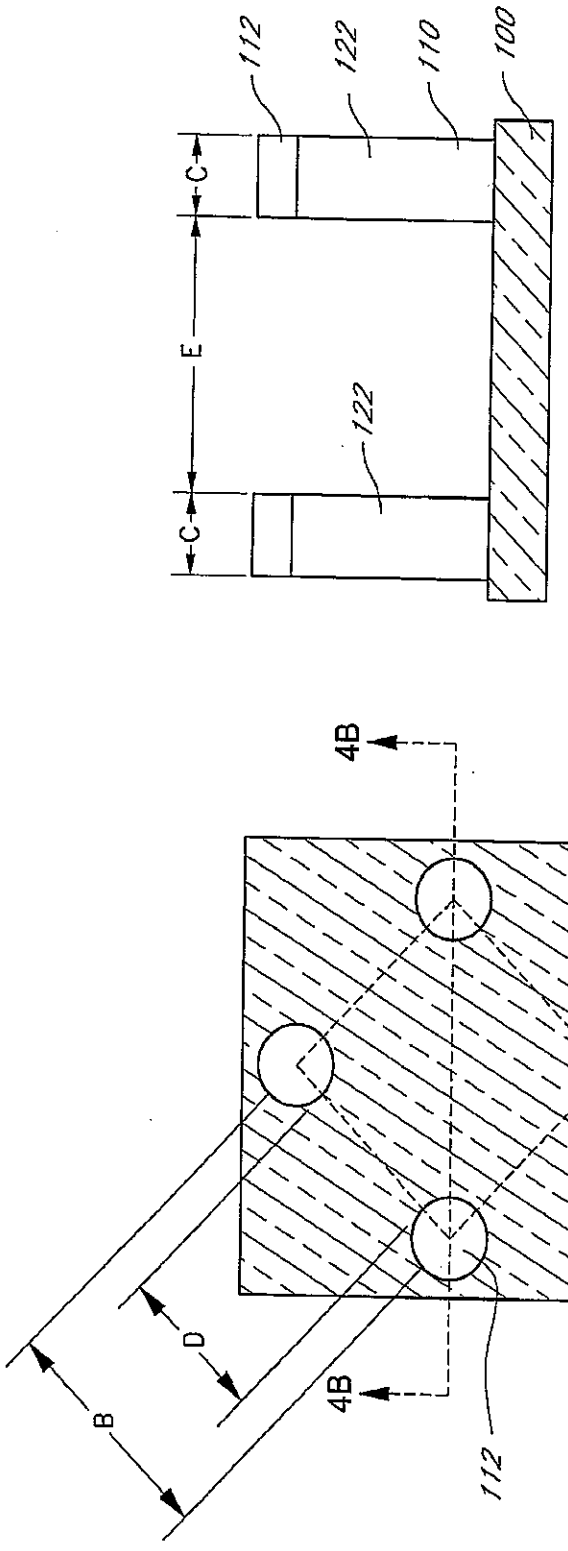


FIG. 4A

FIG. 4B

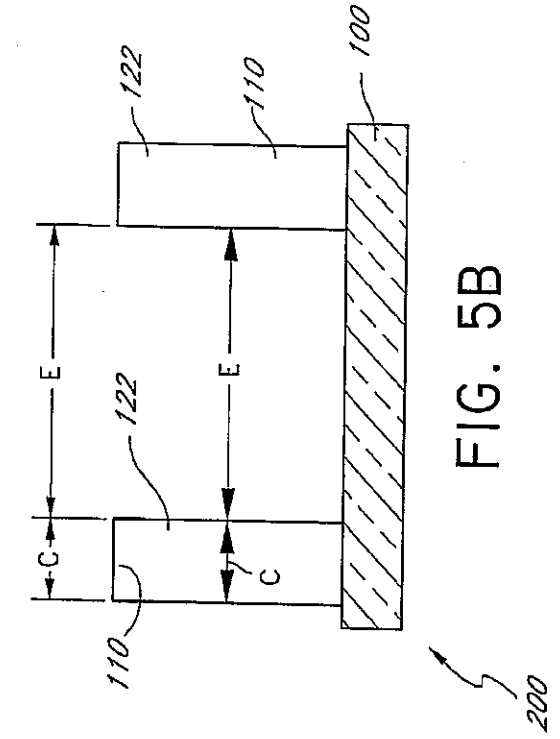


FIG. 5B

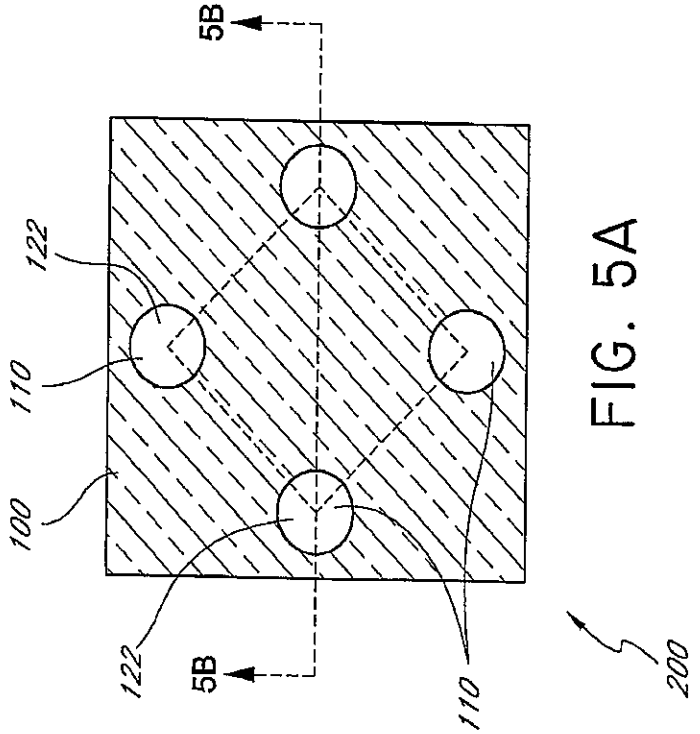


FIG. 5A

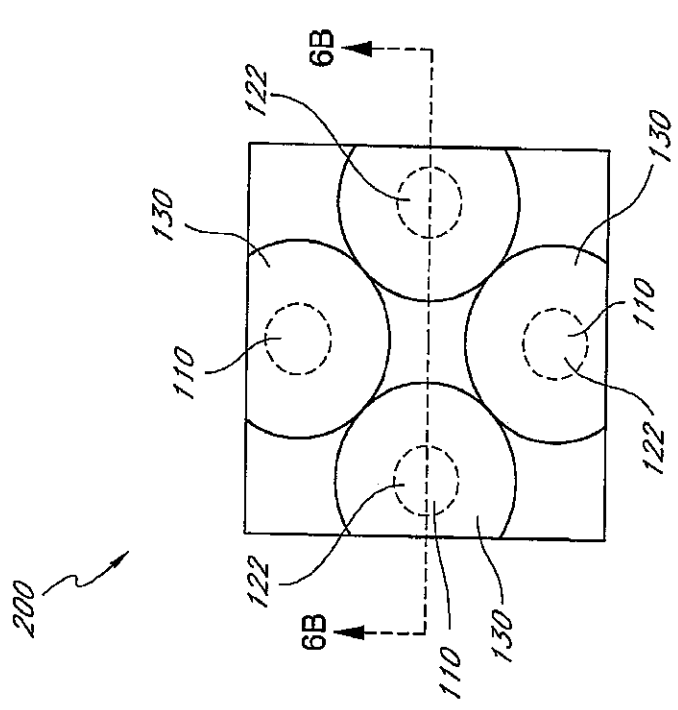

200
6B
6B
122
130
110
122
130
110
122
130
110
122
130
110

FIG. 6A

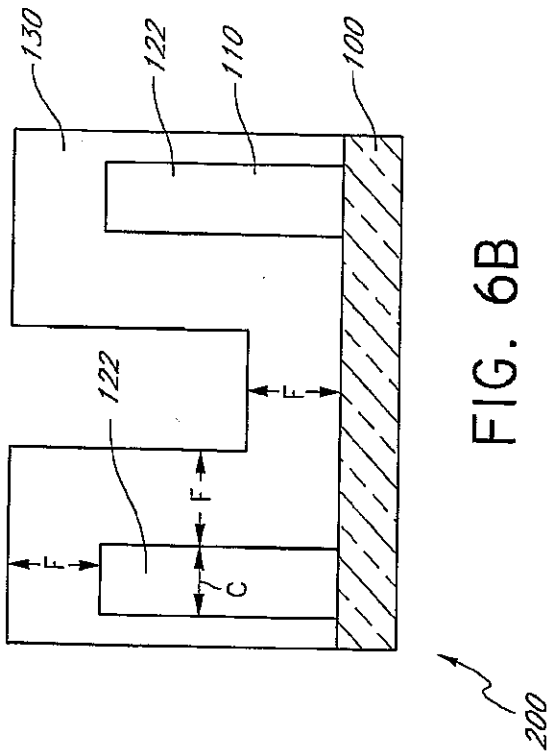

130
122
110
100
F
F
F
C
122
200

FIG. 6B

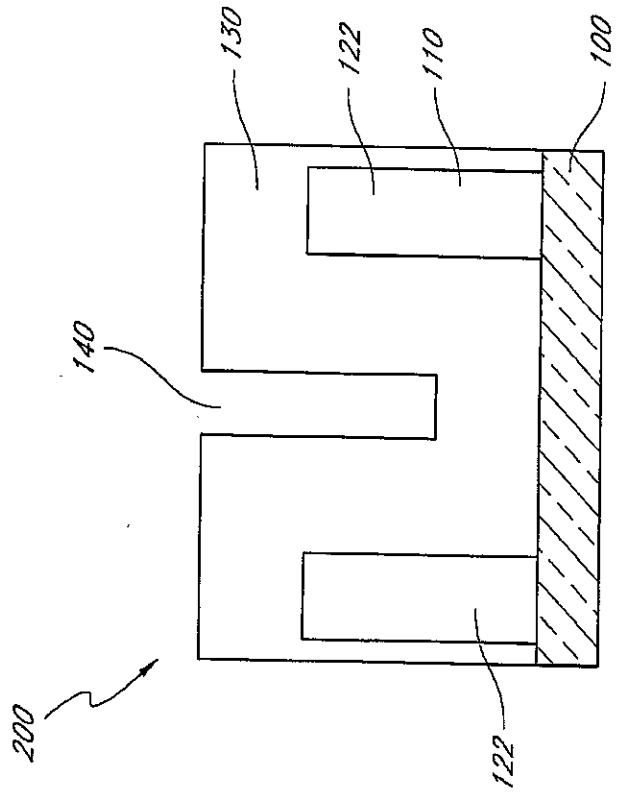

130
122
110
100
140
200
122

FIG. 7B

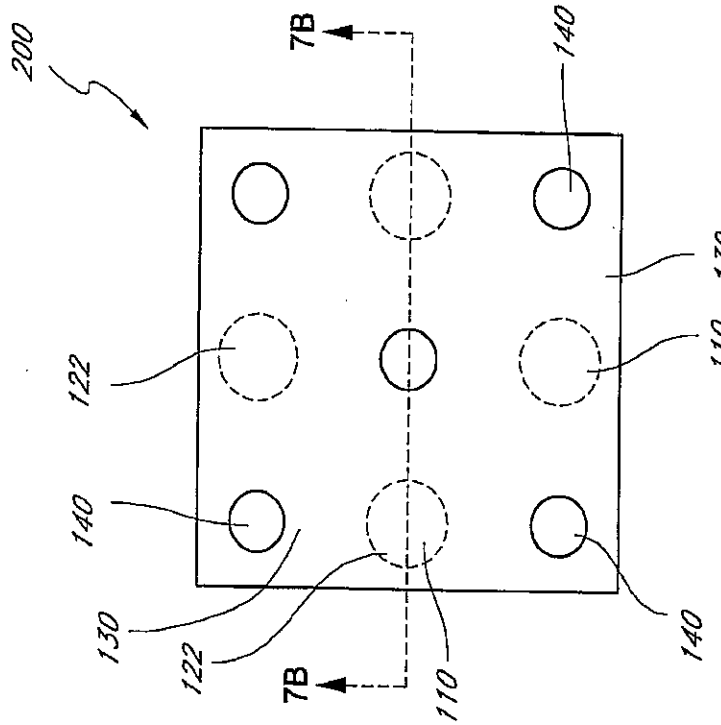

200
7B
140
130
122
110
140
130
122
7B
110
140

FIG. 7A

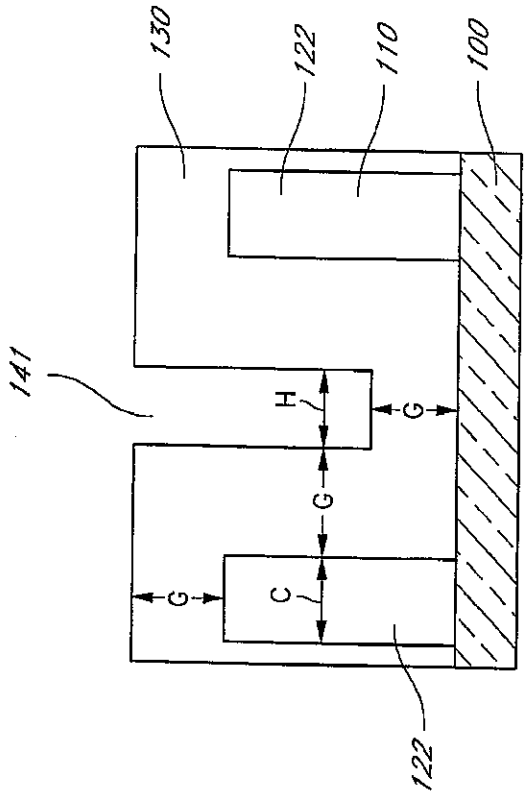

130
122
110
100
141
H
G
G
C
G
122
200

FIG. 8B

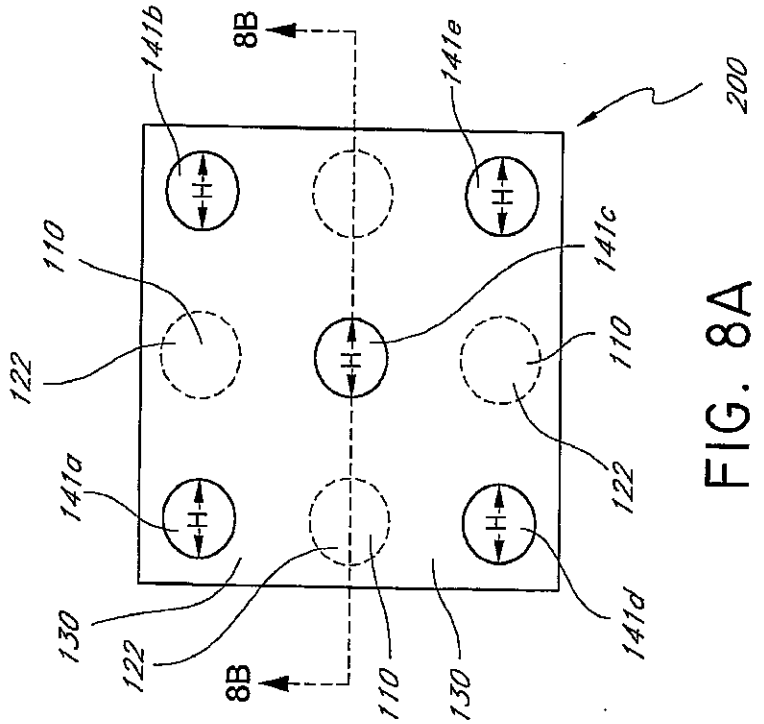

8B
141b
141e
200
110
122
141c
H
141a
130
122
8B
110
130
141d

FIG. 8A

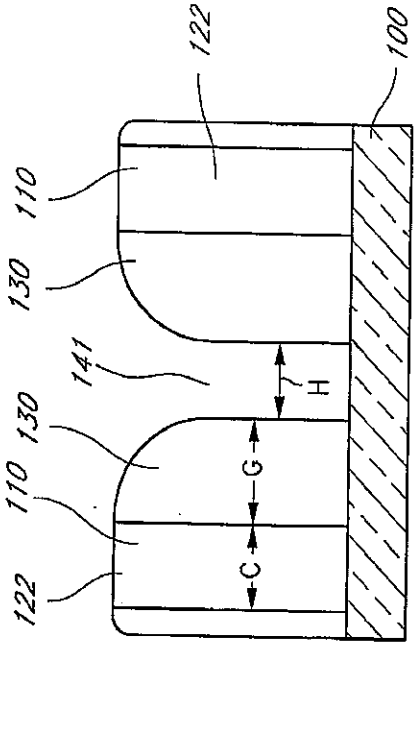

122
100
110
130
141
H
130
G
110
C
122
200

FIG. 9B

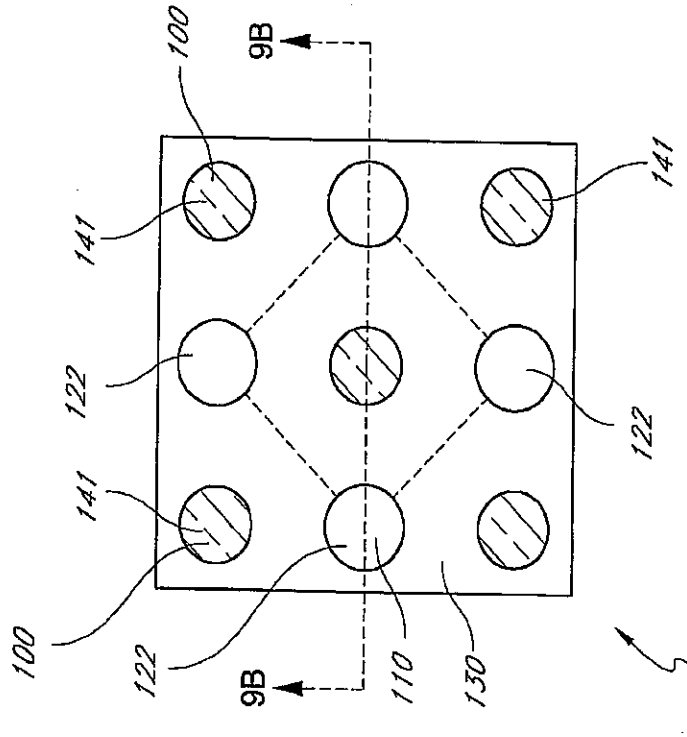

100
9B
141
141
122
122
141
100
122
9B
110
130
200

FIG. 9A

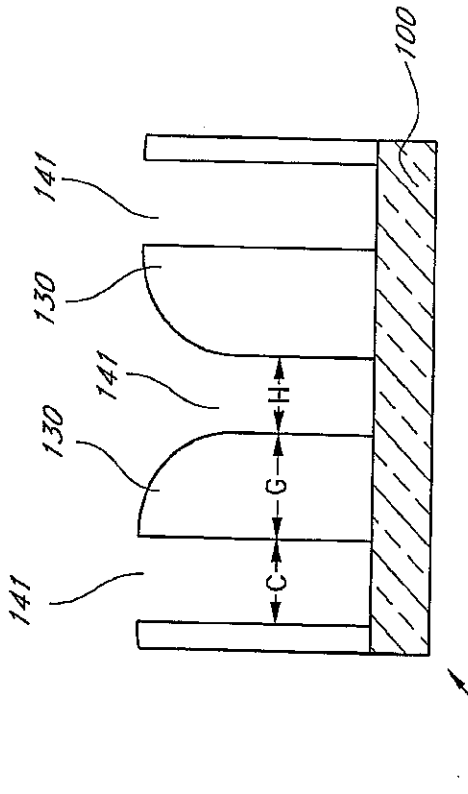


FIG. 10B

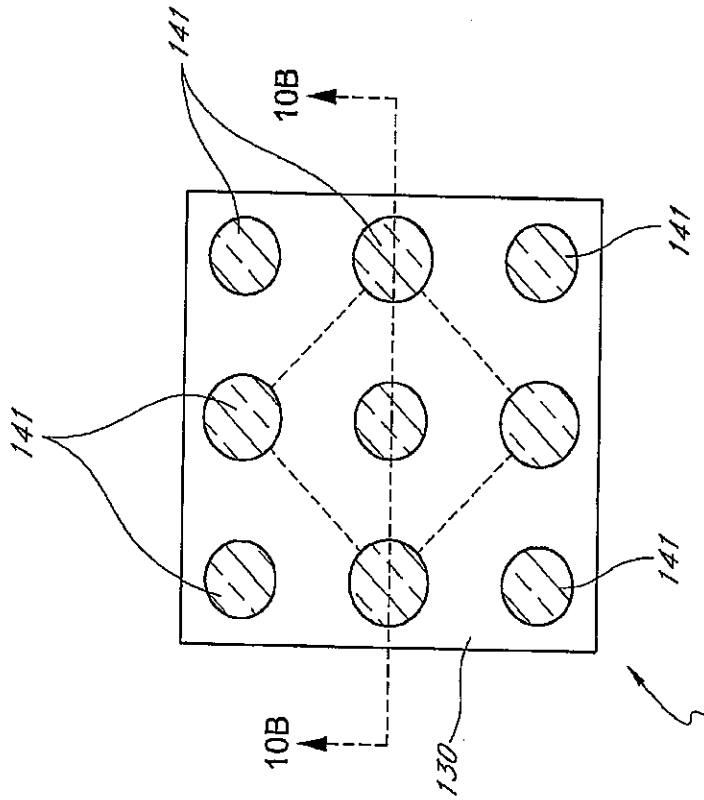


FIG. 10A

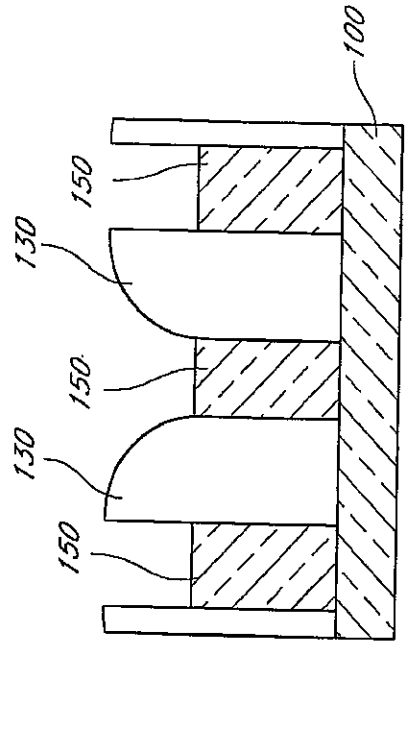


FIG. IIB

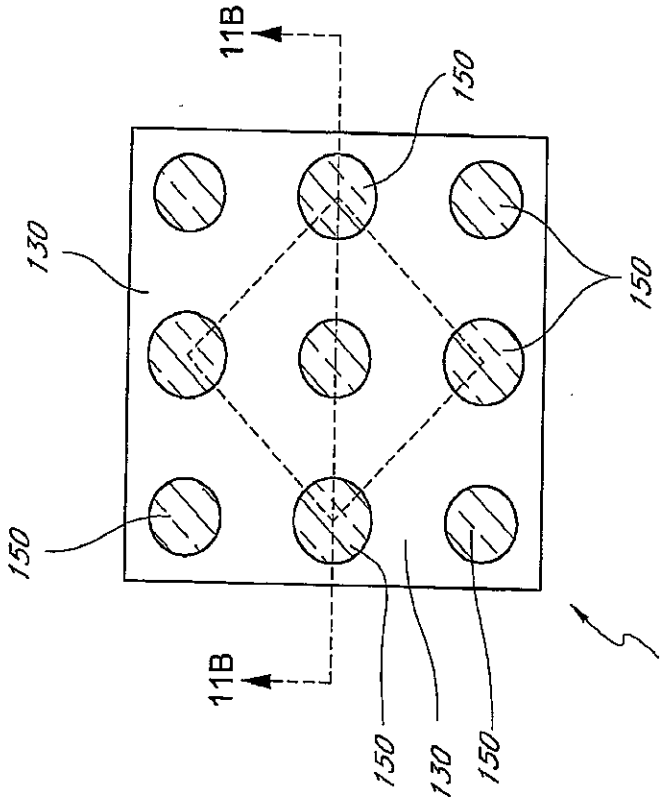


FIG. IIA

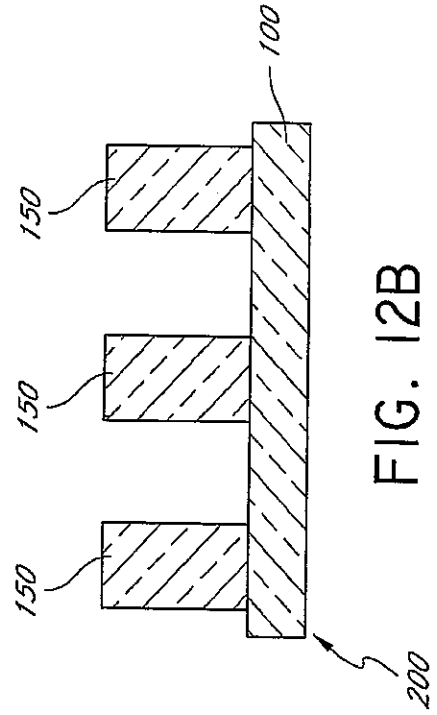


FIG. 12B

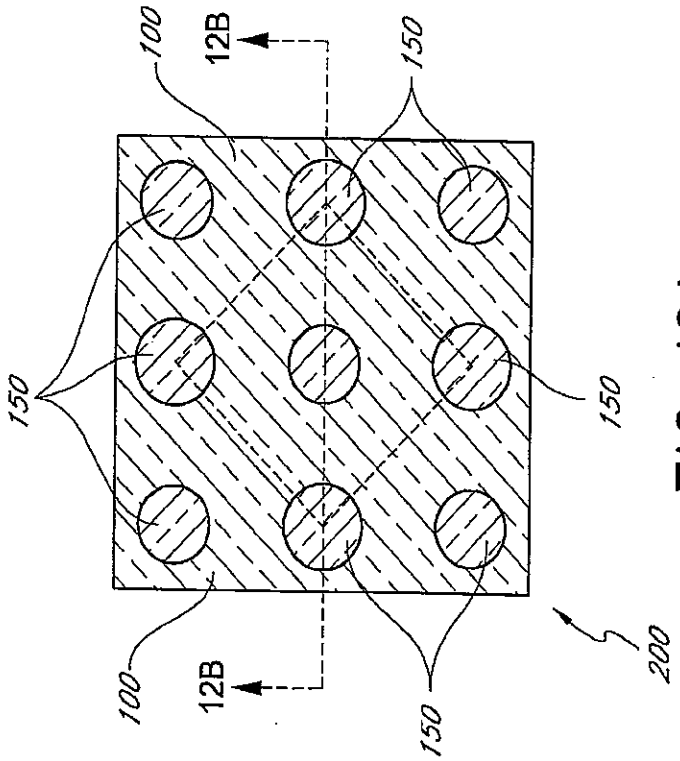


FIG. 12A